

## UNITED STATES DEPARTMENT OF COMMERCE

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ATTORNEY DOCKET NO FIRST NAMED INVENTOR APPLICATION NO. **FILING DATE** 98-0616.02 09/652,841 08/31/00 AGARWAL **EXAMINER** MM91/0412 CHARLES B BRANTLEY II PAPER NUMBER MICRON TECHNOLOGY INC MAIL STOP 525 8000 S FEDERAL WAY 2815 DATE MAILED: BOISE ID 83716-9632

04/12/01

Please find below and/or attached an Office communication concerning this application or proceeding.

**Commissioner of Patents and Trademarks** 

Office Action Summary	Application No.	Applicant(s)
	09/652,841	AGARWAL, VISHNU K.
	Examiner	Art Unit
	José R. Díaz	2815
The MAILING DATE of this communication appears on the cover sheet with the correspondence address Period for Reply		
A SHORTENED STATUTORY PERIOD FOR REPLY IS SET TO EXPIRE 3 MONTH(S) FROM THE MAILING DATE OF THIS COMMUNICATION.  - Extensions of time may be available under the provisions of 37 CFR 1.136 (a). In no event, however, may a reply be timely filed after SIX (6) MONTHS from the mailing date of this communication.  - If the period for reply specified above is less than thirty (30) days, a reply within the statutory minimum of thirty (30) days will be considered timely.  - If NO period for reply is specified above, the maximum statutory period will apply and will expire SIX (6) MONTHS from the mailing date of this communication.  - Failure to reply within the set or extended period for reply will, by statute, cause the application to become ABANDONED (35 U.S.C. § 133).  - Any reply received by the Office later than three months after the mailing date of this communication, even if timely filed, may reduce any earned patent term adjustment. See 37 CFR 1.704(b).  Status		
1) Responsive to communication(s) filed on	·	
2a)  This action is <b>FINAL</b> . 2b)  Th	nis action is non-final.	
3) Since this application is in condition for allowance except for formal matters, prosecution as to the merits is closed in accordance with the practice under <i>Ex parte Quayle</i> , 1935 C.D. 11, 453 O.G. 213.		
Disposition of Claims		
4)⊠ Claim(s) <u>1-3</u> is/are pending in the application.		
4a) Of the above claim(s) is/are withdrawn from consideration.		
5) Claim(s) is/are allowed.		
6)⊠ Claim(s) <u>1-3</u> is/are rejected.		
7) Claim(s) is/are objected to.		
8) Claims are subject to restriction and/or election requirement.		
Application Papers		
9) The specification is objected to by the Examiner.		
10) The drawing(s) filed on is/are objected to by the Examiner.		
11) The proposed drawing correction filed on is: a) approved b) disapproved.		
12) The oath or declaration is objected to by the Examiner.		
Priority under 35 U.S.C. § 119		
13) Acknowledgment is made of a claim for foreign priority under 35 U.S.C. § 119(a)-(d) or (f).		
a) ☐ All b) ☐ Some * c) ☐ None of:		
1. Certified copies of the priority documents have been received.		
2. Certified copies of the priority documents have been received in Application No		
3. Copies of the certified copies of the priority documents have been received in this National Stage application from the International Bureau (PCT Rule 17.2(a)).		
* See the attached detailed Office action for a list of the certified copies not received.		
14) Acknowledgement is made of a claim for domestic priority under 35 U.S.C. § 119(e).		
Attachment(s)		
<ul> <li>15) ⊠ Notice of References Cited (PTO-892)</li> <li>16) ☐ Notice of Draftsperson's Patent Drawing Review (PTO-948)</li> <li>17) ☑ Information Disclosure Statement(s) (PTO-1449) Paper No(s)</li> </ul>	19) Notice of Informa	ary (PTO-413) Paper No(s) Il Patent Application (PTO-152)

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## **DETAILED ACTION**

## Claim Rejections - 35 USC § 102

➤ The following is a quotation of the appropriate paragraphs of 35 U.S.C. 102 that form the basis for the rejections under this section made in this Office action:

A person shall be entitled to a patent unless -

- (e) the invention was described in a patent granted on an application for patent by another filed in the United States before the invention thereof by the applicant for patent, or on an international application by another who has fulfilled the requirements of paragraphs (1), (2), and (4) of section 371(c) of this title before the invention thereof by the applicant for patent.
- ➤ Claims 1-3 rejected under 35 U.S.C. 102(e) as being anticipated by Cuchiaro et al. (US Patent No. 6,165,802).

Regarding claim 1, Cuchiaro et al. teach a method of treating a semiconductor device (see columns 1-16), comprising: providing a capacitor (118) having a first plate (120), a dielectric (122) over said first plate, and a first conductive layer (124) over said dielectric (see figure 1); and exposing said first conductive layer to an N2/H2 plasma (see col. 10, lines 43-45).

Regarding claim 2, Cuchiaro et al. teach providing an in-process capacitor and a second conductive layer (126) over said first conductive layer (see Figure 1).

Regarding claim 3, Cuchiaro et al. teach defining a top plate with said first conductive layer (124) and said second conductive layer (126) (see Figure 1).

## Conclusion

The prior art made of record and not relied upon is considered pertinent to applicant's disclosure. Takaishi (US Patent No. 5,726,083) disclose process of

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fabricating DRAM having storage capacitor low in contact resistance and small in

leakage current through tantalum oxide film.

Correspondence

Any inquiry concerning this communication or earlier communications from the

examiner should be directed to José R. Díaz whose telephone number is (703) 308-

6078. The examiner can normally be reached on 8:00 - 5:00 Monday through Fridays.

If attempts to reach the examiner by telephone are unsuccessful, the examiner's

supervisor, Eddie C. Lee can be reached on (703) 308-1690. The fax phone numbers

for the organization where this application or proceeding is assigned are (703) 308-7722

for regular communications and (703) 308-7722 for After Final communications.

Any inquiry of a general nature or relating to the status of this application or

proceeding should be directed to the receptionist whose telephone number is (703) 308-

0956.

**JRD** 

April 9, 2001

EDDIE LEE

SUPERVISORY PATENT EXAMINER

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